

Notice of Allowability	Application No.	Applicant(s)	
	10/004,152	MANDELMAN ET AL.	MANDELMAN ET AL.
	Examiner	Art Unit	
	David S Blum	2813	
The MAILING DATE of this communication appeal claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED or other appropriate comm GHTS. This application is	n this application. If not included nunication will be mailed in due course. TH	IS iative
1. X This communication is responsive to 5/19/04.			
2. ☑ The allowed claim(s) is/are <u>1-20</u> .			
3. $igotimes$ The drawings filed on <u>10 September 2002</u> are accepted by	the Examiner.		
4.	been received. been received in Application and the communication to fill ENT of this application. Itted. Note the attached EX is reason(s) why the oath of the submitted. It be submitted. It is application and the communication to fill experience and the communication to fill exper	on No ed in this national stage application from the din this national stage application from the area reply complying with the requirements. AMINER'S AMENDMENT or NOTICE OF or declaration is deficient. W (PTO-948) attached r in the Office action of the drawings in the front (not the back) of FR 1.121(d). ERIAL must be submitted. Note the	e
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/06 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview S Paper No. B), 7. ☐ Examiner's	nformal Patent Application (PTO-152) ummary (PTO-413), /Mail Date Amendment/Comment Statement of Reasons for Allowance	

This action is in response to the appeal briefed filed 5/19/04.

Reasons for Allowance Subject Matter

- 1. Claims 1-20 are allowed.
- 2. The following is an examiner's statement of reasons for allowance:

Claims 1 and 12 limit the formation of multi-depth apertures (trenches, or grooves) to providing a pad stack, a single blocking mask, and sequentially (ordered by listing steps a, b, c, etc.) etching a first set of apertures through exposed portions and after removing the mask, etching the first set of apertures to deepen them and etching a second set of apertures in a second etch. This limitation, in combination with the other limitations of claims 1 or 12 is not taught or suggested by the prior art of record. The examiner is persuaded by the applicant's argument that the two mask process of Verret (US005298450A) as modified by the single mask process of Chan (US006207534B1) would then use only the single etch step of Chan to etch both trench depths, and not the two etch steps required by the claims.

Claims 2-11 are allowed as being properly dependent upon allowed claim 1.

Claims 13-20 are allowed as being properly dependent upon allowed claim 12.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David S. Blum whose telephone number is (571)-272-1687) and e-mail address is David.blum@USPTO.gov.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr., can be reached at (571)-272-1702. Our facsimile number all patent correspondence to be entered into an application is (703) 872-9306. The facsimile number for customer service is (703)-872-9317.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

David S. Blum

July 14, 2004